Tool ID: 216 Tool Location: 111

# **Equipment Information Sheet**

# **Xactix Xenon Difluoride Etcher**

Backup: Tom Pennell 607-254-4309

Manager: Jeremy Clark 607-254-6487 Calls to staff phones will be automatically forwarded to their cell phones during accessible hours. At other times

Minimum Tool Time: 15 minutes

leave a message or send them an email.

#### **SAFETY**

• System uses a vapor Fluorine source for etching - use caution during operation

# **USAGE RESTRICTIONS**

• No buddy system restrictions

## SCHEDULING/SIGN-UP RESTRICTIONS

• None

### MATERIALS COMPATIBILITY CATEGORY

Tool Category 5: Class A and B Metals and Compounds	
Allowed	Not Allowed
Tool category 1/1E, 2, 3, and 4 materials	
Silicon Based Substrates and Films	
III/V compound Semiconductors	
Glass Substrates	
PECVD and ALD Films	
Cured organics and baked Photoresist	
CNF Class A, B, and Refractory metals	
Exposed Gold, Silver, Copper	
Alkali and Alkaline Compounds	
Organic/Biology Molecules prepared- w/salt buffers	
High Vapor Pressure Materials (Mg, Ca, Zn)*	* Some tool restrictions on high vapor pressure materials may apply
Soft organic materials	

High Vapor Pressure Metals and Compounds are materials that have a vapor pressure above 1e-6 Torr at 400 C.

#### **Additional Material Restrictions and Exceptions**

- Wafers up to 150 mm
- Pieces are allowed as well

Last Updated: 03/24/2021